

ENTERED BY CEH21105 Docket No.: M4065.0319/P319

## IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Patent Application of:

Examiner: Erik Kielin

Ronald A. Weimer, et al.

Art Unit: 2813

Application No.: 09/296,835

Filed: April 22, 1999

For: METHOD OF FABRICATING A

SEMICONDUCTOR DEVICE WITH A DIELECTRIC FILM USING A WET **OXIDATION WITH STEAM PROCESS** 

## AMENDMENT IN RESPONSE TO AFTER-FINAL OFFICE ACTION

**Commissioner for Patents** 

MS: Amendment P.O. Box 1450

Alexandria, VA 22313-1450

Dear Sir:

This paper is in response to the Office Action dated January 11, 2005. Please amend the above-identified U.S. patent application as follows:

Amendments to the Claims are reflected in the listing of claims which begins on page 2 of this paper.

Remarks begin on page 5 of this paper.

DSMDB.1911180.2